

Adamas $15/150 \ \mu \text{m}$

 $[N_s] \approx 100 \text{ ppm}$ $[NV] \approx 3 \text{ ppm}$

Vacuum 3 mm

Chemical Vapour Deposition

(CVD)

Gas feed (CH4, H2)

-substrate

microwave

plasma ball

IRCP-LSPM $[N_s] \approx 25 \text{ ppm}$

 $[NV] \approx 4.5 \text{ ppm}$